IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application	of Christoph Nölscher
Serial No.: No	t Yet Assigned
Filed: Herewith	ı ·
	Method for Forming a Structure Element on a Wafer by Means of a Mask and a Crimming Mask Assigned Hereto

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. §1.97(b)

Pursuant to the duty imposed by 37 C.F.R. §1.56 to disclose information which may be material to the patentability of the above-identified patent application, the Applicant(s) would like to direct the Examiner's attention to the documents listed on the enclosed Information Disclosure Citation Form (PTO/SB/08). In accordance with this duty of disclosure, Applicant(s) hereby submits the following information in conformance with 37 C.F.R. §§1.97 and 1.98.

ormance	with 37 C.F.R. §§1.97 and 1.98.
	Pursuant to 37 C.F.R. §1.98, a copy of each document cited in the attached Form PTO/SB/08 is enclosed.
	The subject Information Disclosure Statement is being filed without copies of the listed U.S. Patents and/or U.S. patent application publications pursuant to the waiver of the requirement under 37 C.F.R. §1.98(a)(2)(i) for applications filed after June 30, 2003. Copies of the listed foreign patent documents and/or non-patent literature are enclosed herewith.
	No copies of the publications listed on the attached Form PTO/SB/08A are being provided pursuant to 37 C.F.R. §1.98(d) because the publications were previously cited by or submitted to the Office in prior Application Serial No to which the above-identified application claims priority under 35 U.S.C. §120.
	Publication(s) listed on the attached Form PTO/SB/08A were cited in a foreign search or examination report corresponding to application serial no and mailed on

	§609 c	of the M.P.E.P., Applicant	submits 1	cation(s) Pursuant to the attached foreign search or English language publication(s).
	langua	sed is a copy of a non-Englage publication (cop h publication.		cation(s) English ed) claims priority from this non-
		sed is an explanation of nor glish translation is not avai	_	n publication(s) for which
		sed is an English translation attached Form PTO/SB/08		non-English publication(s) cited
\boxtimes		sed is an English Abstract of 8 for which an English tran		n-English publication(s) <u>JP 2001-</u> s not available.
	Enclos	sed is a copy of pending pa	tent App	lication Serial No
This Is time periods:	nformat	ion Disclosure Statement is	s filed wi	thin any one of the following
		within three months from other than a CPA under 3		g date of this national application § 1.53(d);
				of entry of the national stage as international application;
	\boxtimes	before the mailing date of	f a first o	ffice action on the merits; or
		before the mailing of a fir request for continued exact		action after the filing of a under 37 C.F.R. § 1.114.
It is re	spectful	lly requested that the Exam	niner con	sider the above-noted
information a	nd retur	n an initialed copy of the a	ttached F	Form PTO/SB/08A to the
undersigned.				•
Dated: 12	·		D.,,	Respectfully submitted by EDELL, SHAPIRO & FINNAN, LLC
EDELL, SHAP CUSTOMER N		· · · · · · · · · · · · · · · · · · ·	Ву:	Patrick J. Finnan
1901 Research Rockville, MI (301) 424-364	20850	vard, Suite 400		Reg. No. 39,189

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				Application Number	Not Yet Assigned	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT				Filing Date	Herewith	
				First Named Inventor	Christoph Nölscher	
				Group Art Unit	Unknown	
	(use as many s	heets as	s necessary)	Examiner Name	Unknown	
Sheet	1	of	2	Attorney Docket Number	0928.0016C	

U.S. PATENT DOCUMENTS							
		U.S. Patent Document			D. CD.III is a Co.		
	Cite No.1	Number	Kind Code ² (if known)	Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY		
		6,171,730	B1	Kuroda et al.	01-09-2001		
		6,466,373	Bi	Pforr et al.	10-15-2002		
		6,573,027	B1	Imai	06-03-2003		
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FOREIGN PATENT DOCUMENTS							
Examiner Initials*	Cite No.1	. I FOREIGH FALENT DOCUMENT I				Date of Publication	
	No.	Office ³	Number ⁴	Kind Code ⁵ (if known)	Name of Patentee or Applicant of Cited of Cited Docu	of Cited Document MM-DD-YYYY	T⁵
			JP 2001-144178	A	Sony Corporation	05-25-2001	
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Examiner	Date	 -
Signature	Considered	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹ Unique citation designation number. ² See attached Kinds of U.S. Patent Documents.

³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3).

For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible.

⁶ Applicant is to place a check mark here if English language Translation is attached.

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Substi	itute for form 14	49B/PT0)	Application Number	Not Yet Assigned	
	. .			Filing Date	Herewith	
INF	ORMATIC	ON DI	SCLOSURE	First Named Inventor	Christoph Nölscher	
l STA	TEMENT	BY A	PPLICANT	Group Art Unit	Unknown	
	(use as many s	heets as	s necessary)	Examiner Name	Unknown	
Sheet	2	of	2	Attorney Docket Number	0928.0016C	

OTHER DOCUMENTS - NON PATENT LITERATURE DOCUMENTS					
Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²		
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^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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